

## REMARKS

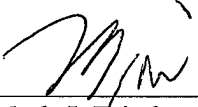
A telephonic interview between Applicant's representative and the Examiner was conducted on January 17, 2007. Applicant's proposed amendments for overcoming the prior art rejection with regard to claims 1, 10, 17, and 24 were discussed and no agreement was reached.

In response to the Examiner's interview, Applicants have amended claims 1, 10, 17, and 24 (i.e., as discussed with the Examiner) to include the limitation of: selectively exposing only a **single feature** (i.e., comprising a critical dimension error) of a plurality of features (i.e., formed within a photo resist layer) to an electron beam to correct the critical dimension error. In contrast, the Examiner's prior art reference Wong (U.S. 6,340,556) teaches in col. 8, lines 18-22 that "The electron beam irradiating is conducted with a uniform, large-area, overall electron beam exposure source which **simultaneously** exposes substantially **all of the image areas** of the photosensitive composition **simultaneously**". Therefore, Applicants contend that Wong teaches a process for electron beam exposing **all** image areas on a structure (i.e., all image areas comprising errors) and does not teach **selectively exposing only a single** photo resist feature (i.e., comprising a critical dimension error) of a plurality of features as taught by Applicant's claims 1, 10, 17 and 24.

### CONCLUSION

Prompt and favorable examination on the merits is respectfully requested. Applicants respectfully submit that the entire application is in condition for allowance. However, should the Examiner believe anything further is necessary in order to place the application in better condition for allowance, or if the Examiner believes that a telephone interview would be advantageous to resolve the issues presented, the Examiner is invited to contact the Applicant's undersigned representative at the telephone number listed below. The Director is hereby authorized to charge and/or credit Deposit Account 19-0513.

Date: 1/19/07

  
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